



**EXPEDITED PROCEDURE – EXAMINING GROUP 2818**

S/N 09/471,460

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Thomas A. Figura et al. Examiner: Calvin Lee  
Serial No.: 09/471,460 Group Art Unit: 2818  
Filed: December 22, 1999 Docket No.: 303.932US4  
Title: USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE  
FORMATION OF A SEMICONDUCTOR DEVICE

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**AMENDMENT & RESPONSE UNDER 37 C.F.R. 1.116**

Mail Stop RCE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

In response to the Final Office Action mailed August 22, 2005, please amend the application as follows:

This response is accompanied by a Petition, as well as the appropriate fee, to obtain a one-month extension of the period for responding to the Office action, thereby moving the deadline for response from November 22, 2005 to December 22, 2005.